## B.VOC FASHION TECHNOLOGY SEMESTER II PAPER CODE: BVFT-205B

Paper Title: PATTERN MAKING AND GARMENT CONSTRUCTION- II (Lab)
Paper/Module Code:BVFT205B

Maximum Marks:50

Objectives: To develop skill in the area pattern making with special emphasis on basics of garments design

Unit-I	Dart manipulation: slash & spread method, Pivot method.	10
	Dart Manipulation- conversion of darts to tucks, pleats, gathers, seam	
	lines etc.	
Unit-II	Sleeves- plain, gathered, leg-o-mutton, kimono	20
	Collars -Flat, rolled collars, mandarin, shirt, sailor	
	Yokes-With and without fullness style lines	
	Pockets- Patch pockets, Patch pockets with flap, Inseam pockets, welt	
	kurta pockets	
	Plackets- one side extended, both side extended, concealed.	
Unit-III	Skirt variations: Basic-flared, circular, gathered, pleated, basic waist band	20
	application	

\*\*\*\*